52. (Amended) The method of claim 51 wherein the [chlorine] fluorine is provided in the gate oxide layer to a concentration of from about 1 x  $10^{19}$  atoms/cm<sup>3</sup> to about 1 x  $10^{21}$  atoms/cm<sup>3</sup>.

 $\mathcal{D}^{\prime}$ 

53. (Amended) The method of claim 51 wherein the gate comprises opposing lateral edges and a central region therebetween, the [chlorine] fluorine being provided within the gate oxide layer to a greater concentration proximate at least one of the gate edges than in the central region.